

<b>FORM 1449*</b> <b>INFORMATION DISCLOSURE STATEMENT</b>  <b>IN AN APPLICATION</b> (Use several sheets if necessary)	Docket Number: 70020.0063USWO	Application Number: 10/533,254
	Applicant: Hiroyuki ISHII, <i>et al.</i>	
	Filing Date: April 29, 2005	Group Art Unit:

U.S. PATENT DOCUMENTS								
EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
/ACW/	AA	10/533,223	4/29/2005	Nishimura, <i>et al.</i>				
/ACW/	AB	2004/0146802	7/29/2004	Yamamoto, <i>et al.</i>				
/ACW/	AC	2003/0203309	10/30/2003	Nishimura, <i>et al.</i>				
/ACW/	AD	2005/0214680	9/29/2005	Miyaji, <i>et al.</i>				
/ACW/	AE	2004/0048192	3/11/2004	Shima, <i>et al.</i>				
/ACW/	AF	6,800,419	10/5/2004	Soyano, <i>et al.</i>				
/ACW/	AG	6,403,280	6/11/2002	Yamahara, <i>et al.</i>				
/ACW/	AH	6,482,568	11/19/2002	Douki, <i>et al.</i>				
/ACW/	AI	6,933,094	8/23/2005	Miyaji, <i>et al.</i>				
FOREIGN PATENT DOCUMENTS								
		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
/ACW/	AJ	05-188598	7/30/1993	JAPAN			Abstract	
/ACW/	AK	06-012452	1/21/1994	JAPAN			Abstract	
/ACW/	AL	09-073173	3/18/1997	JAPAN			Abstract	
/ACW/	AM	2000-026446	1/25/2000	JAPAN			Abstract	
/ACW/	AN	2002-145955	5/22/2002	JAPAN			Abstract	
/ACW/	AO	2002-156750	5/31/2002	JAPAN			Abstract	
/ACW/	AP	2002-201232	7/19/2002	JAPAN			Abstract	
/ACW/	AQ	2002-251013	9/6/2002	JAPAN			Abstract	
/ACW/	AR	2002-372784	12/26/2002	JAPAN			Abstract	
/ACW/	AS	2003-043690	2/13/2003	JAPAN			Abstract	
/ACW/	AT	2003-206315	7/22/2003	JAPAN			Abstract	

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EXAMINER	/Amanda C. Walke/	DATE CONSIDERED	01/07/2008
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.			